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Cold Atmospheric Plasma: Sources, Processes, and Applications

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Message from the Guest Editors

Dear Colleagues,

Cold atmospheric plasma (CAPs) have earned their place within the broader field of plasma technology, branching out in many other major disciplines, including catalysis, biomedical engineering, medicine, energy applications, waste treatment, agriculture, etc., thanks to their versatility in design, ease of implementation, low cost and unique chemical composition.

This Special Issue in particular will focus on CAPs used for surface modification processes. Surface and interface enhancement of materials in general continues to generate a lot of interest in any discipline, as it allows to maintain interesting bulk material properties of low-tech materials such as strength, weight and elasticity while making them suitable for high-tech applications.

The overall goal of this Special Issue is to cover the employed plasma sources, the innovative processes under development, the envisioned applications and the future challenges to be tackled by the scientific community.

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